

Preliminary program of the 2 day workshop: "Plasma Science & Interfaces"

Program Morning 18 October 2018

07.30	Hall open for table booth installations	
08.30	Doors open/coffee	
09.00	Welcome & Opening by Chair(s) Philipp Rudolf von Rohr and Dirk Hegemann & Program Director Hugo de Haan	
9.20-9.50	1 st keynote; Christian Oehr , Fraunhofer Institute for Interfacial Engineering and Biotechnology IGB, Plasma functional thin films	
9.50-10.10	Coffee / tea at booth area	
	Start parallel workshop sessions	
	Plasma medicine, medical and healthcare Moderator: KD Weltmann	Plasma Surface modification & thin films Moderator:
10.10-10.30	KD Weltmann , INP Greifswald,	Ken Heenen , IMO / Uni Hasselt, "Applications of Conductive Nanocrystalline Diamond Films by Plasma-driven Microstructure Tailoring"
10.30-10.50	Paola Brun , University of Padova, "Effects of cold plasma generated by ionization of a helium flow on wound healing"	Patrick Choquet , LIST & Regis Heyberger, "Functional thin films deposited by Plasma-assisted deposition at Atmospheric Pressure using Dielectric Barrier Discharges"
10.50-11.10	Guus Peemen , Technical University Eindhoven, "Sustainable fertilizer from plasma activated water"	Philippe Roquiny , AGC Plasma Technology Solutions, "From Lab to Industrial Scale Plasma Tools"
11.10-11.30	Peter Awakowicz , RUB, "Plasma sterilization of thermolabile materials"	Uwe Lommatzsch , Fraunhofer IFAM, Bremen, Germany, "Plasma coating processes at low and atmospheric pressure and the transfer to industrial applications - adhesion promotion, corrosion protection and biocompatible coatings"
11.30-11.50	Coffee Break	
	Plasma medicine, medical and healthcare Moderator: Kerstin Thorwarth	Plasma Surface modification & thin films Moderator: Fabienne Poncin-Epaillard
11.50-12.10	Kerstin Thorwarth , Empa, CH	Fabienne Poncin-Epaillard , Université du Maine / le Mans, France, "Enhancement of practical adhesion of PEEK surfaces Enhancement of practical adhesion of PEEK surfaces Enhancement of practical adhesion of PEEK thanks to plasma technologies"
12.10-12.30	Ravi Sinha , University Of Maastricht / MERLN;	Patrice Raynaud , Université Paul Sabatier de Toulouse, "Low pressure PECVD of metal oxide and metal oxide/silica thin films: Comparative study of films deposited from metalorganic precursors Zirconium Tetra tert-Butoxide and Titanium Tetra Isopropoxide"
12.30-12.50	Ainhoa Pardo , EMPA, "Interface corrosion and fatigue mechanisms investigations in DLC coated articulating implants"	Lenka Zajíčková , CEITEC, CZ," Plasma polymer coatings on electrospun polymer nanofibers aimed at biomedical applications"
12.50-13.10	Papken Hovsepian , Sheffield Hallam University, Sheffield, UK, "Development of nanoscale multilayer CrN/NbN coatings for joint replacements deposited by High Power Impulse Magnetron Sputtering"	
13.10-14.00	Photo shoot participants & Lunch	

Program Afternoon 18 October 2018

	Atmospheric pressure plasma @ Micro/Nano scale Moderator: David Pai	Atmospheric pressure plasma jet (APPJ) Moderator: Judith Golda
14.00-14.20	David Pai , University Poitiers, "In-situ fluid and surface diagnostics of atmospheric-pressure microplasmas"	Judith Golda , Institute of Experimental and Applied Physics, Kiel University, Germany,. "The COST-Jet as a versatile tool for science: fundamental research and applications"
14.20-14.40	Gary Eden , Illinois University, USA,	Iuliia Onyshchenko , Ghent University, Belgium "Improving APPJ treatment with a new design and adjusted operating conditions"
14.40-15.00	Bilel Rais , InnoPhysics /XX	Milan Simek , Academy of Science , Prague, Czech Republic,
15.00-15.20		Andreas Pfuch , INNOVENT e.V. Technology Development. Jenas, Germany, "Atmospheric pressure plasma jet coatings - overview and possibilities in R&D on the way to industrial application"
15.20-15.50	Coffee Break	

	Plasma Surface modification & thin films Moderator: David Duday	Nanoparticles generation and particlesurface treatment Moderator: Philipp Rudolf von Rohr
15.50-16.10	David Duday , LIST, "Generation of surface chemical gradients by an atmospheric-pressure plasma jet"	Roger Wallimann , ETH, "Nanoparticle Formation from HMDSO in Atmospheric Pressure Plasma for the Enhancement of Powder Flowability"
16.10-16.30	Stefan Nettesheim , Relyon Plasma GmbH, Regensburg, Germany, "Piezoelectric Low-Pressure Plasma"	Stefan G. Mayr , IOM Leipzig "Smart biomaterials: energetic particle assisted synthesis and functionalization"
16.50-17.10	Thomas Homola , R&D Center for Low-Cost Plasma and Nanotechnology Surface (CEPLANT), Brno, Czech Republic , "Plasma Processing of Surfaces and Nanostructured Coatings for Flexible and Printed Electronics"	Denis Dowling , School of Mechanical and Materials Engineering, University College Dublin, Ireland "Enhancing the performance of powder particles through atmospheric plasma treatments"
17.10-17.30	Ondrej Kylian , Charles University, Prague , Czech Republic : "Gradient coatings prepared by means of gas aggregation sources"	Ivo Furno , EPFL Lausanne, Swi. "High pressure resonant network antennas for powder treatment"
17.30-17.50	Yuji Ohkubo , Osaka University, Japan, "Adhesive-free strong adhesion between fluoropolymers and other materials via plasma-jet-treated polydimethylsiloxane"	<i>open</i>
17.50-18.50	Coffee Break, ISC Steering Committee Meeting) & Lab tours	
19.00-23.00	Dinner & musical event	

Program Morning 19 October 2018

07.30-8.20	Coffee / tea at booth area	
	Plasma Surface modification & thin films Moderator: Marko Eichler	Plasma Surface modification & thin films Moderator:
08.20- 08.40	Marko Eichler , Fraunhofer IST “Plasma jet applications with oxygen-free process gas mixtures”	Thomas Nelis , Berner Fachhochschule , Institute ALPS, Bern, “
08.40-09.00	François Loyer , Luxembourg Institute of Science and Technology (LIST), Materials Research and Technology (MRT) Department “Atmospheric pressure plasma initiated chemical vapor deposition (AP-PiCVD) – temporally isolated discharges toward conventional polymerization”	Mathis Trant , EMPA , “Influence of ion flux density on Growth Morphology and Piezoelectric Properties of AlN Thin Films in DC Magnetron Sputtering”
09.00-09.20	Daniel Haehnel , PLASMA ELECTRONIC GMBH, NEUENBURG	Damien Thiry , Chimie des Interactions Plasma Surface (ChIPS), University of Mons (UMONS), Belgium, “A novel approach for micro/nano structuring functionalized plasma polymer films”
09.20-09.40	Gaffar Hossain , V-trion, AT. “Plasma assisted protective nanocoating of outdoor textiles”	Séverine Wolak , CNRS IS2M, “Nanocomposite plasma polymers: from synthesis to smart surface properties”
09.40-10.20	Coffee Break	
10.20-10.50	2 nd keynote: Deborah O’Connell , University of York “Activation of stem cell identity by plasma generated reactive species in primary prostate cells”	
10.50-11.20		
11.20-11.50	Coffee Break	
	Surface diagnostics, energetics, analytics and –metrology Moderator:	Plasma parameterization, diagnostics, simulation Moderator: Antaryami Mohanta
11.50-12.10	Holger Kersten , Uni Kiel, IEAP, AG Plasmatechnologie, Kiel, Germany.	Antaryami Mohanta , EMPA, “Spectroscopic investigation of inductively coupled plasma for understanding synthesis process of graphene nano-flakes”
12.10-12.30	Bernard Nisol , Polytechnique Montreal “Energetics of Plasma Polymerization in Atmospheric Pressure Dielectric Barrier Discharges”	Ursel Fantz , Augsburg University "Monitoring plasma parameters via OES at the example of ion sources"
12.30-12.50	Ezgi Bülbül , Empa, CH, “Investigations on the water penetration into hydrophilic/hydrophobic gradient plasma films”	Reza Abhari , ETHZ, CH
12.50-13.10	Christine Bilke-Krause , Kruss,	Thomas Gilmore , Impedans Ltd., Plasma Research Group, “On modern fault detection methods for industrial plasmas using intelligent impedance sensors”
13.10-14.00	Poster session & Lunch (when no ISC meeting time 18 th ; 13.45 meeting International Scientific Committee / ISC) <i>Posters:</i> <ul style="list-style-type: none"> • Tomas Plichta , Brno University of Technology Adhesion and mechanical properties of a-CSi:H and a-CSiO:H thin films prepared by PECVD • Chako, EMPA • Ganesan , EMPA 	

Program Afternoon 19 October 2018

14.00	Workshop session	
	Plasma for Emission Abatement & CO2 Moderator:	Plasma parameterization, diagnostics, simulation Continued Moderator: Jan Trieschmann
14.00-14.20	Bilel Rais , InnoPhysics, NL,	Jan Trieschmann , Ruhr-Universität Bochum, "Toward a consistent plasma-surface model for sputter processing using machine learning"
14.20-14.40	Francesco Parisi , GRINP, Turin, Italy,	Adam Obrusnik , PlasmaSolve, Brno, Czechia, "Modeling and computer simulation of plasma processing technologies using open-source and the cloud"
14.40-15.00	Luca Matteo Martini , University of Trento, "Nanosecond discharges for CO2 conversion"	Bram Wolf , DIFFER, NL, "CO2 microwave plasma conversion– efficient production of CO at moderate pressures"
15.00-15.20	Vasco Guerra , Instituto Superior Técnico, Lisboa, Portugal, "CO2 plasmas - from solar fuels on Earth to oxygen production on Mars"	Sandra Gaiser , Empa, CH, "Influence of Gas Flow and Pressure on Plasma Deposition Mechanisms"
<i>If required</i>	<i>open</i>	<i>open</i>
15.20-16.00	Plenary Closure @Coffee break Lab tours	